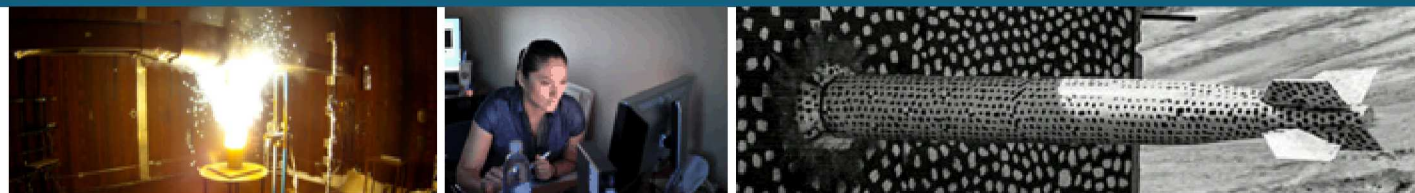


Stabilization of ferroelectric phase of $\text{Hf}_{0.5}\text{Zr}_{0.5}\text{O}_2$ on NbN at 4 K



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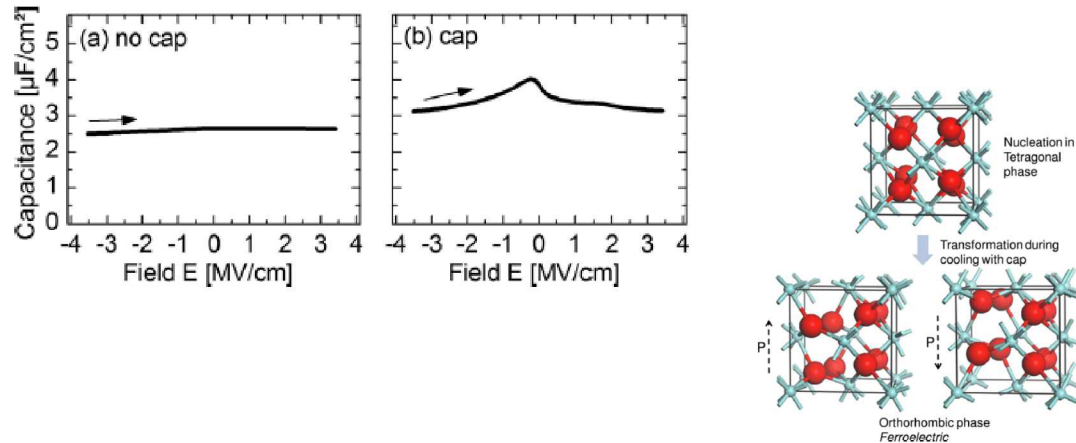
S. W. Smith, R. M. Lewis, T. R. Young, J. F. Ihlefeld*



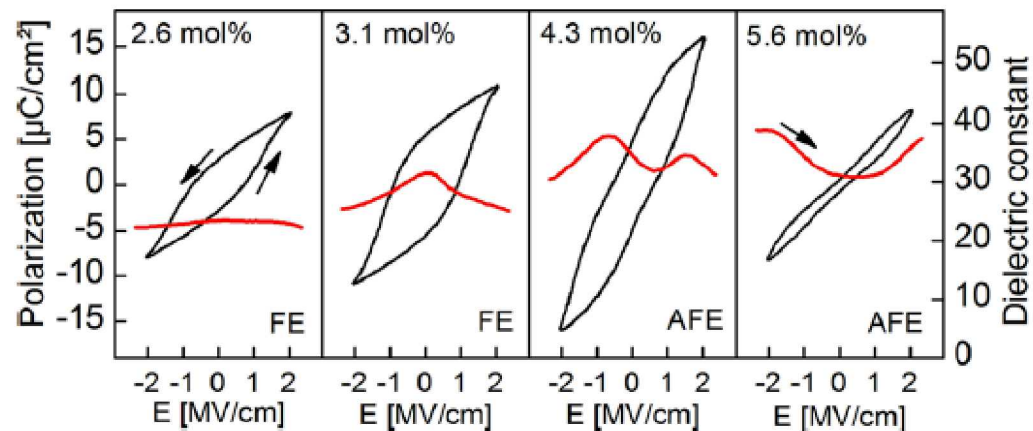
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Outline of Ferroelectricity on Superconducting NbN

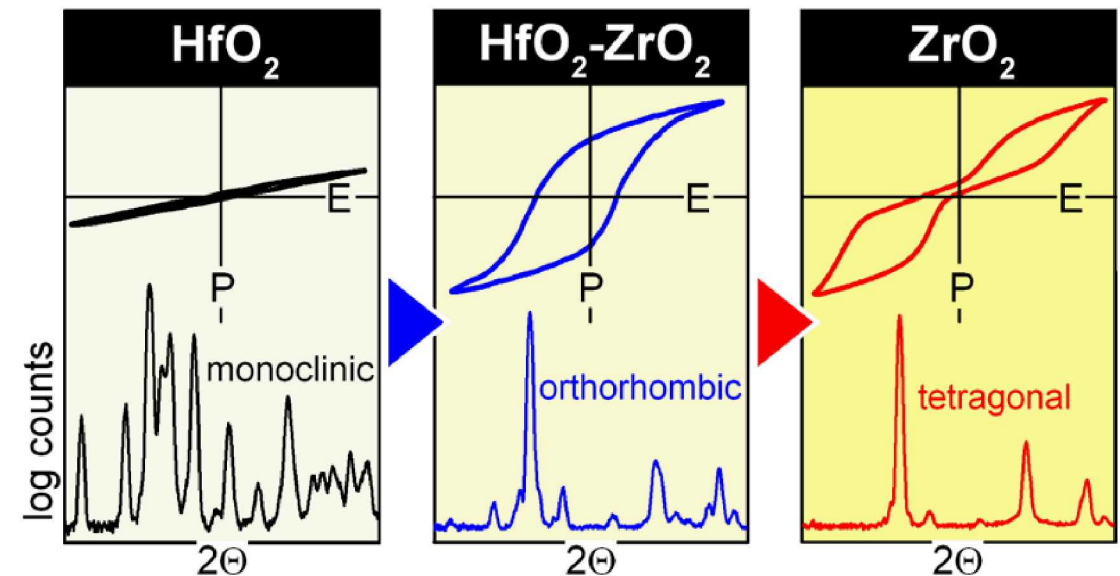
- Introduction into HfO_2 Ferroelectricity
- Behavior of $\text{Hf}_{0.5}\text{Zr}_{0.5}\text{O}_2$ on NbN
 - Cryogenic Behavior
 - Wake-up Effects
 - Electrical Properties
 - Freeze Out of Oxygen Vacancies
- Conclusion



Observation of a polarization of MIM Cap (TiN/HfO₂/TiN) occurring under ideal conditions, can induce an orthorhombic phase to emerge from a tetragonal or monoclinic phase. This amazing discovery led to the idea of mixtures (SiO₂, ZrO₂) and dopants (Si, Gd, La, Y) to improve the ferroelectric response. However, only very specific sets of electrodes were observed to enable this transformation suggesting a close link to the nucleation of the needed phase to the electrodes.

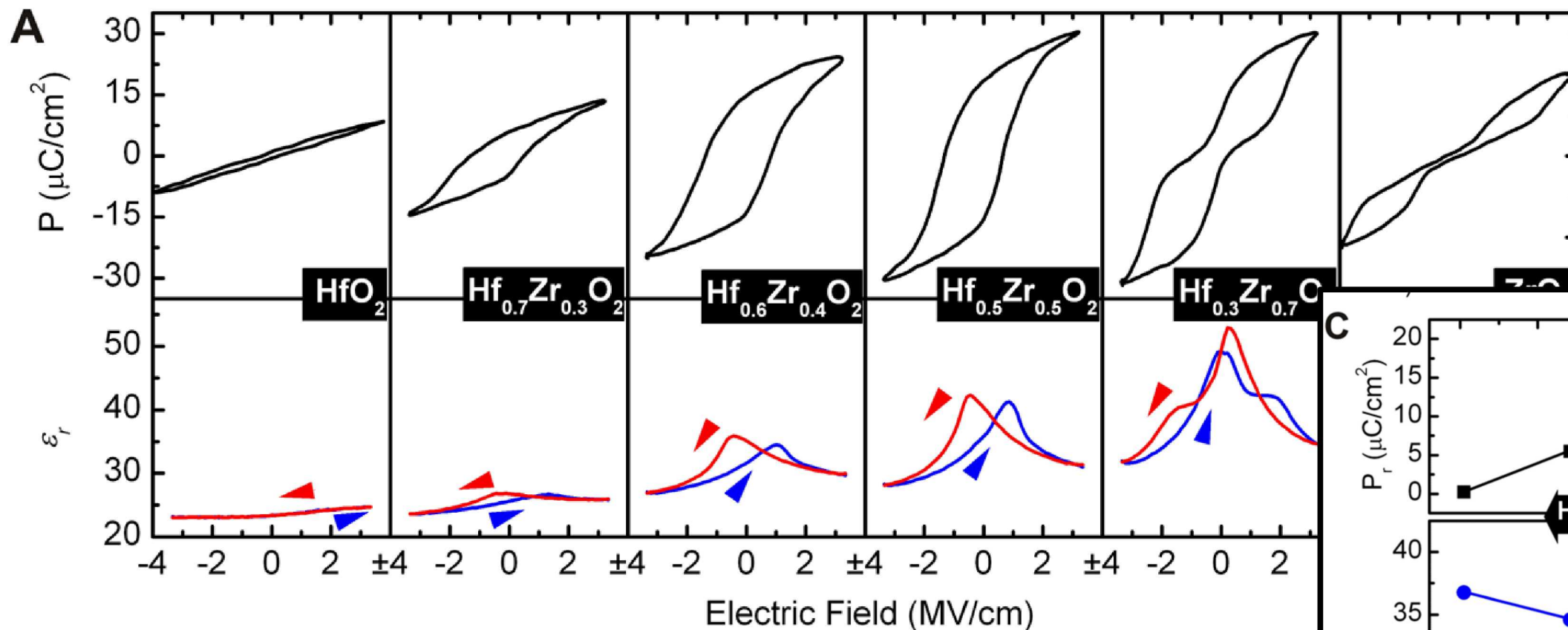


T.S. Boscke et al., APL, 99, 102903, (2011).

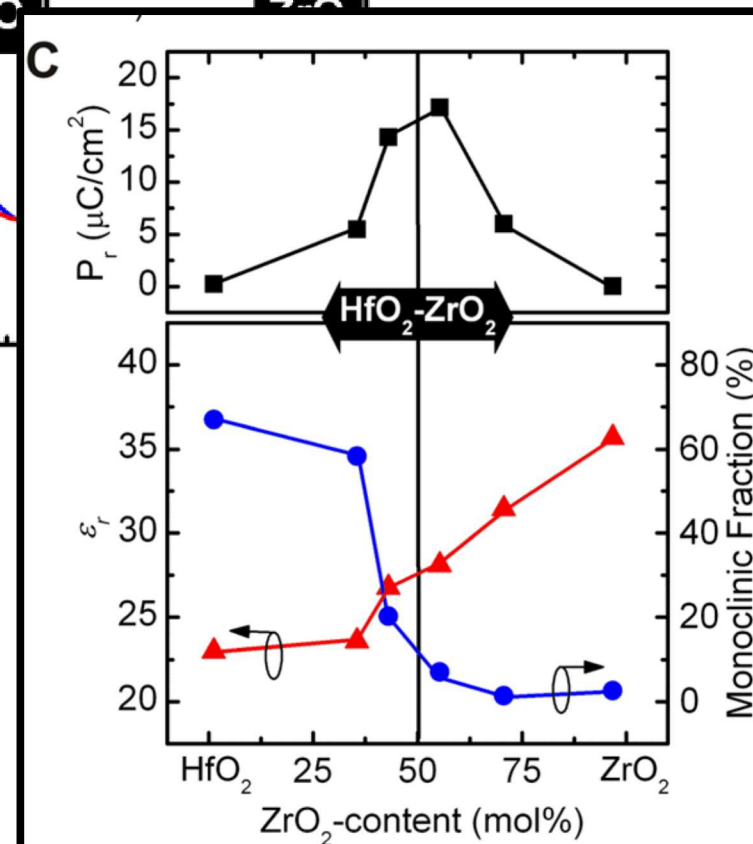


J. Muller et al., Nano Lett., 12, 4318-4223, (2017).

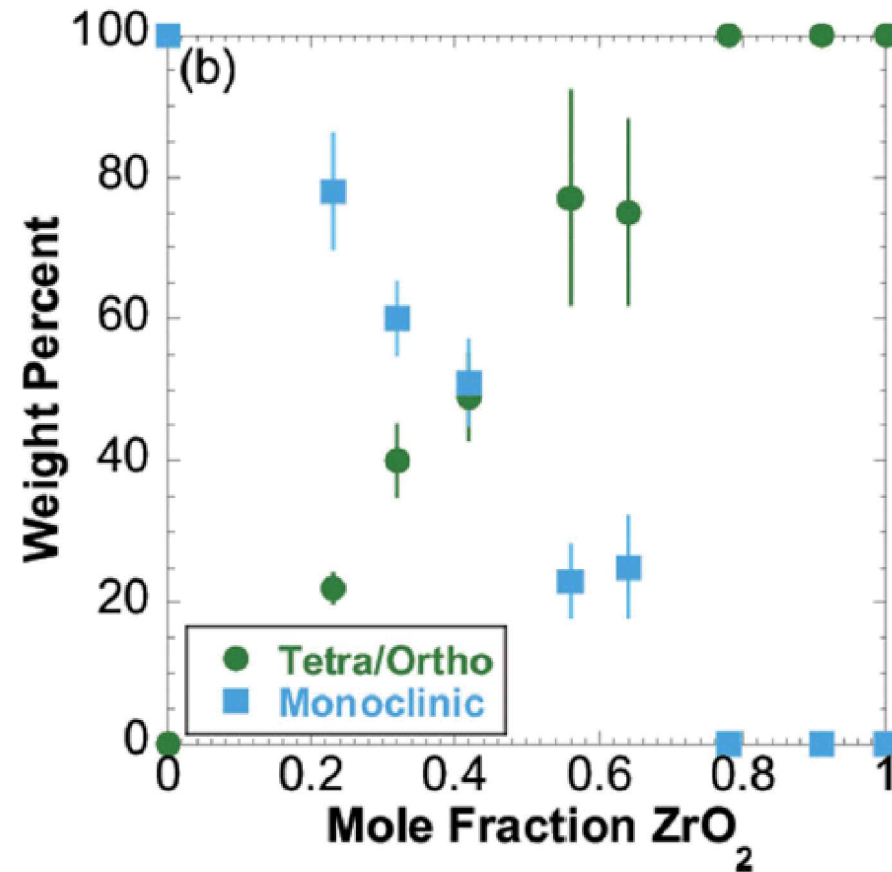
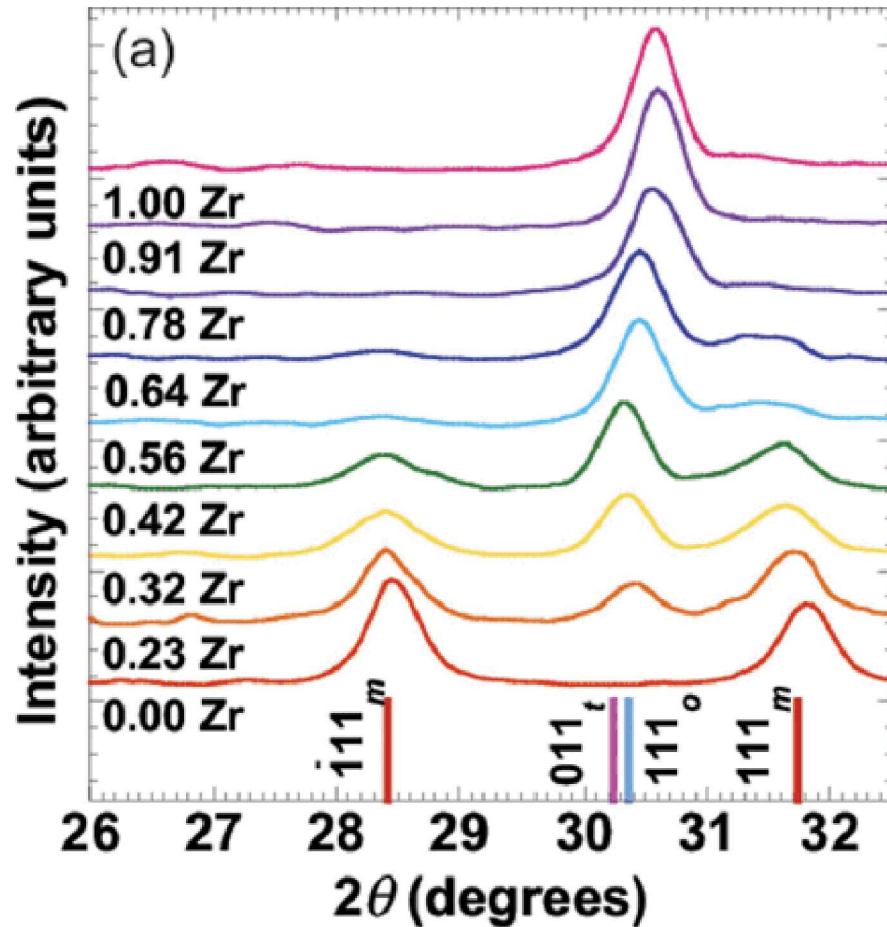
Addition of ZrO_2 to HfO_2 – TiN electrodes



As ZrO_2 is mixed into the ALD process, an improvement in P_r is observed as a stronger ferroelectric phase emerges (ortho). Note ZrO_2 goes antiferroelectric.



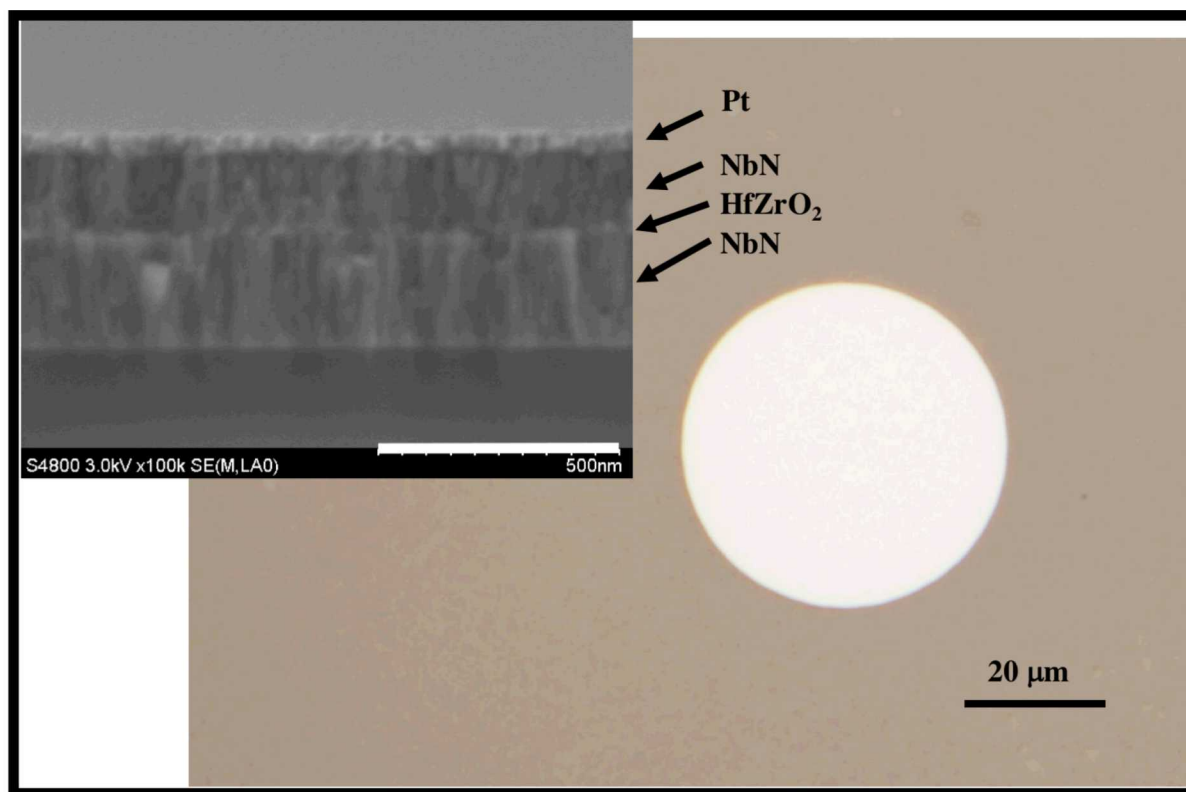
Phase Control and Identification of $\text{Hf}_x\text{Zr}_{1-x}\text{O}_2$ with TaN Electrodes



Knowing which phase is present is seen using GIXRD. As films are pressed from HfO_2 , a transition occurs from monoclinic to tetragonal and orthorhombic.

S.W. Smith et al., APL, 110, 072901 (2017).

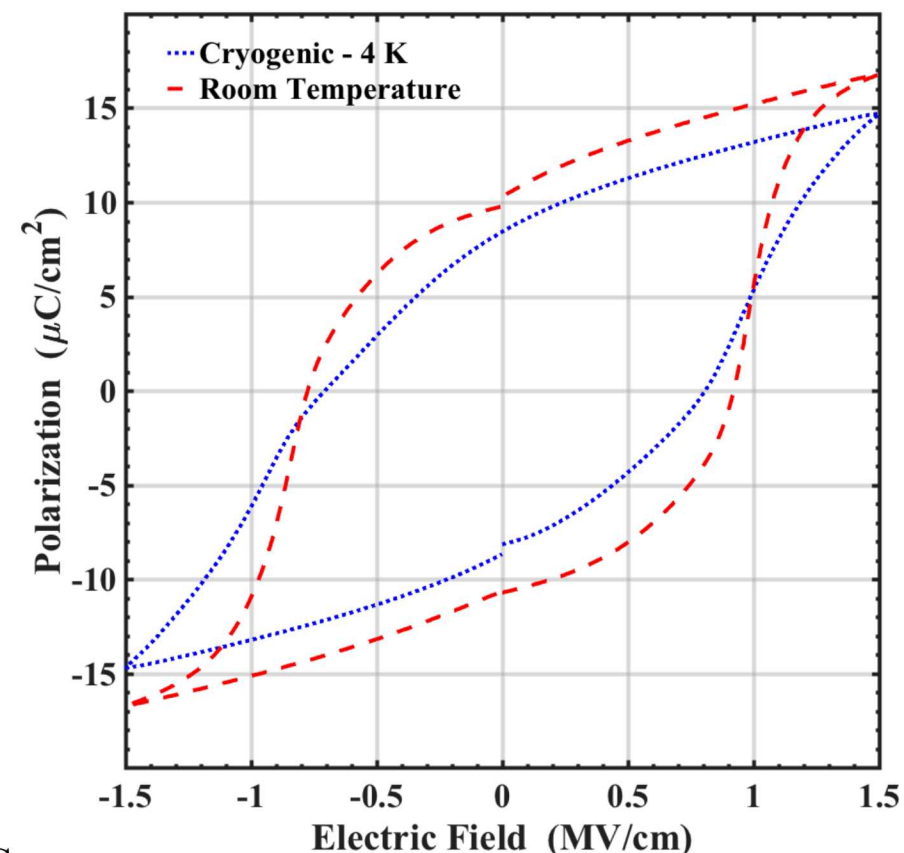
Utilizing NbN Electrodes for $\text{Hf}_{0.5}\text{Zr}_{0.5}\text{O}_2$ (NbN/HZO/NbN)



Using a 20 nm HZO film, a clear ferroelectric phase is observed at room temperature and under cryogenic conditions.

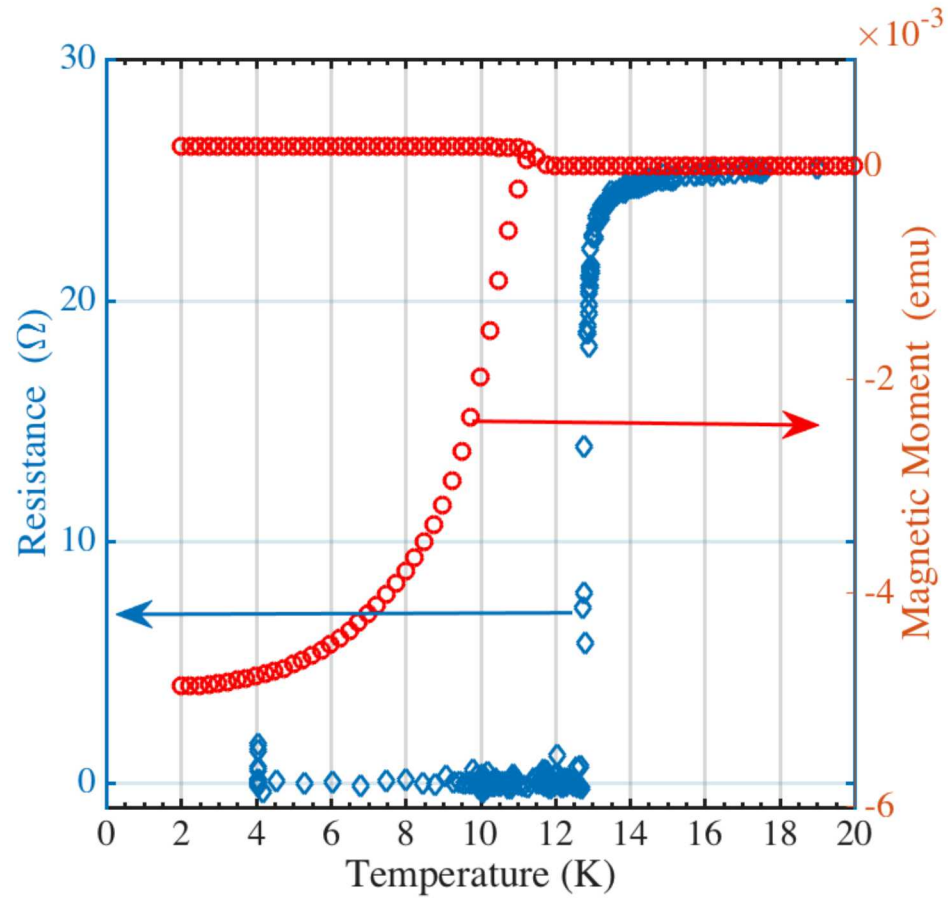
ALD growth was done in an Ultratech Savannah flow-through style ALD reactor. Tetrakis(dimethylamino)hafnium and tetrakis(dimethylamino)zirconium, each at 75 °C, were used as the precursors with water used as the oxidant and N_2 as the carrier gas.

Cryo measurements performed in a LakeShore open flow probe station utilizing a LakeShore 331 stage temperature controller and Precision Multi ferroic II.

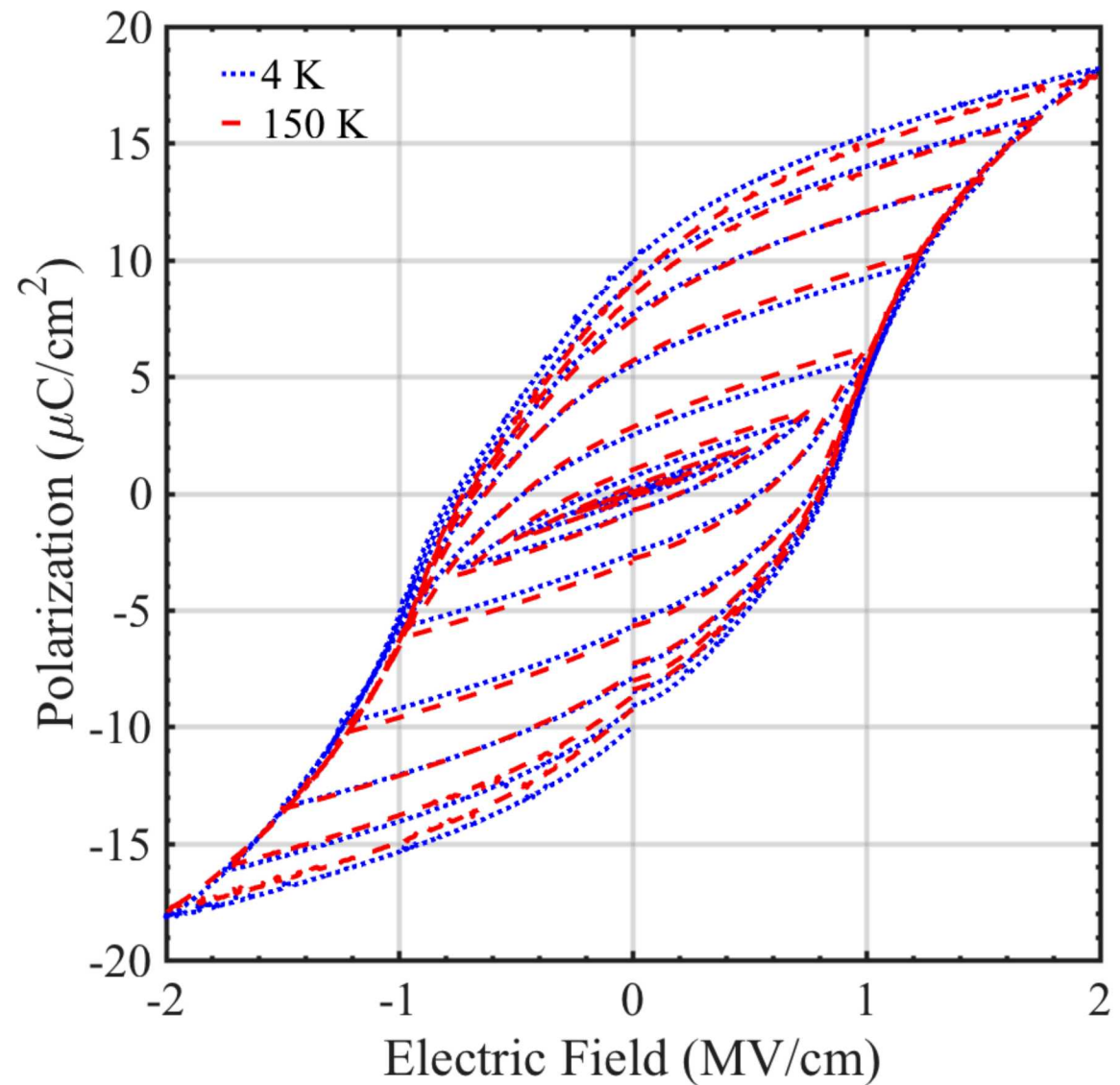


M.D. Henry et al., APL, in submission (2018).

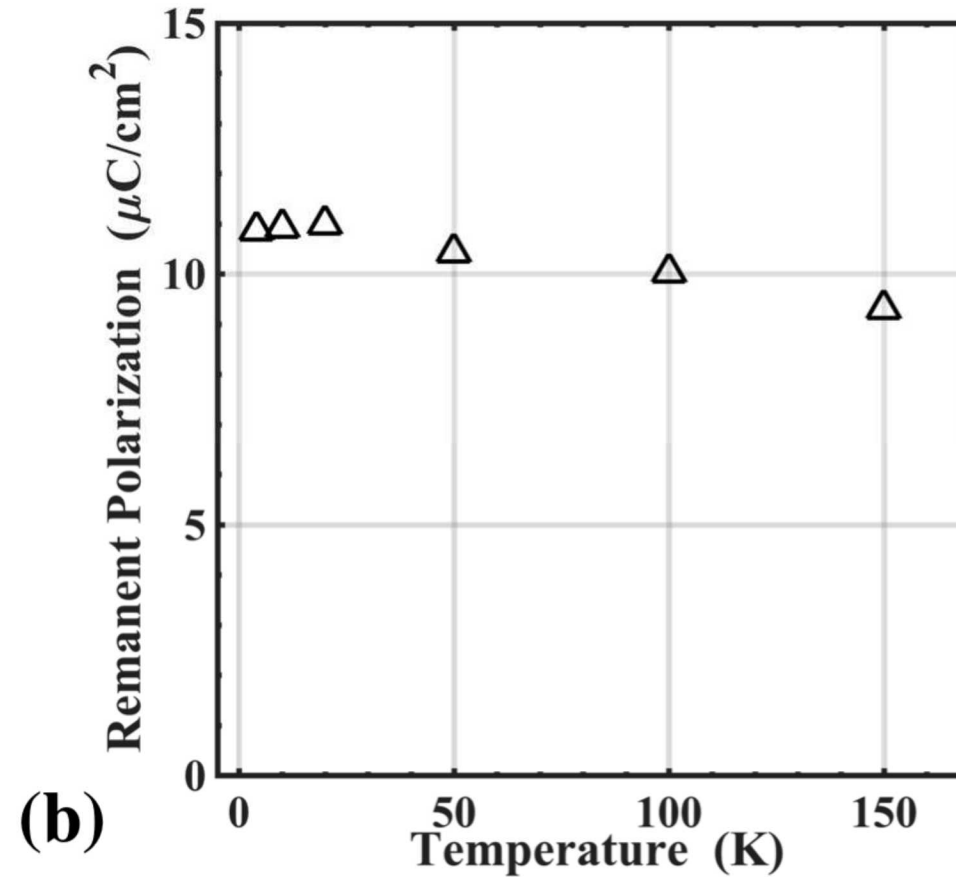
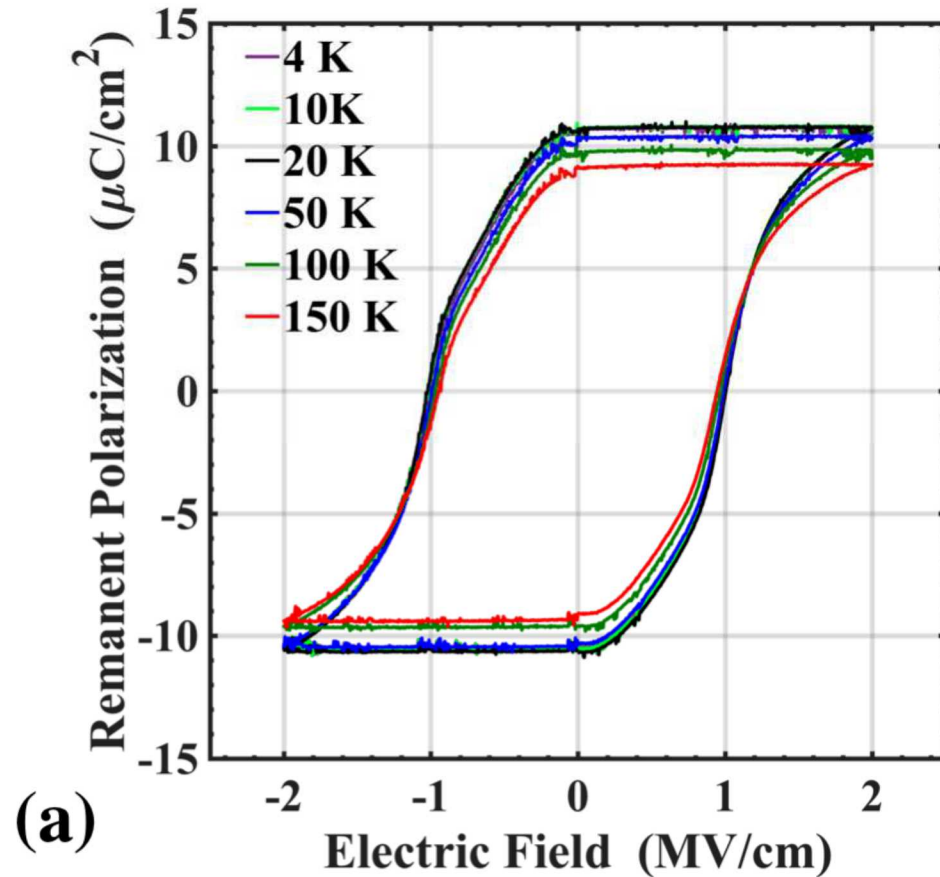
Superconductivity with NbN/HZO/NbN



The 150 nm thick, NbN top electrode was reactively sputtered in a Denton Discovery deposition tool using a 99.5% pure Nb target, Ar and N₂ at room temperature.

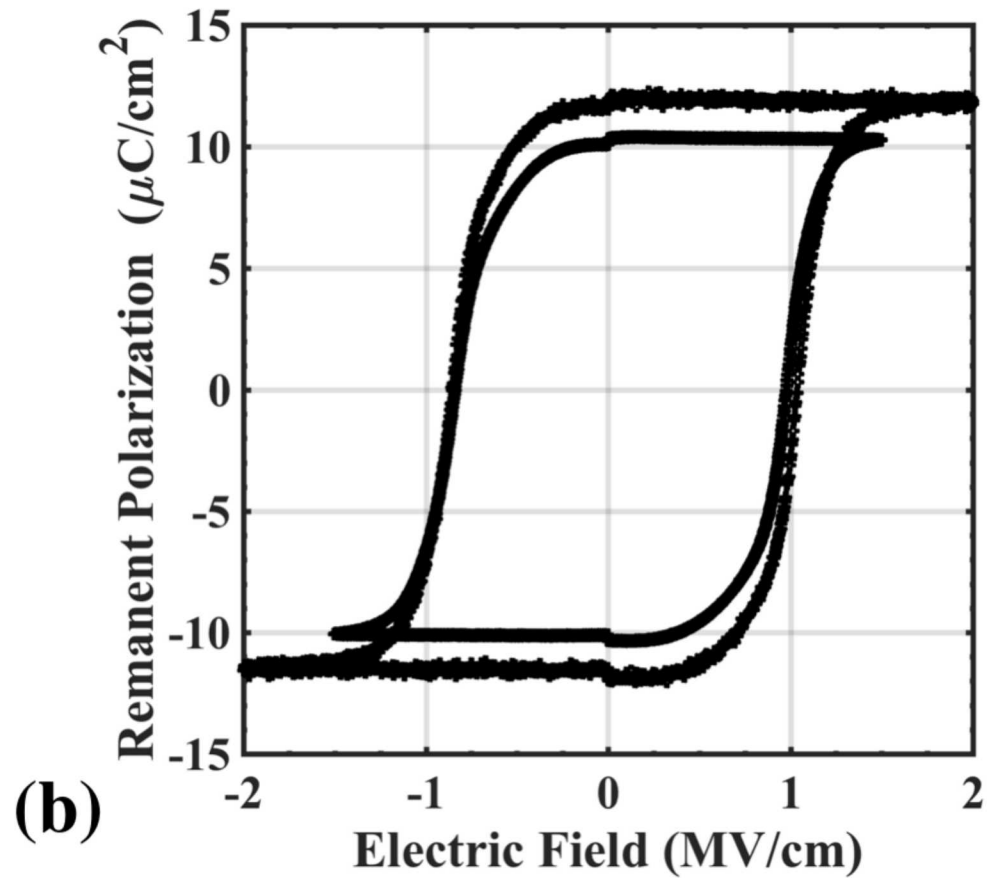
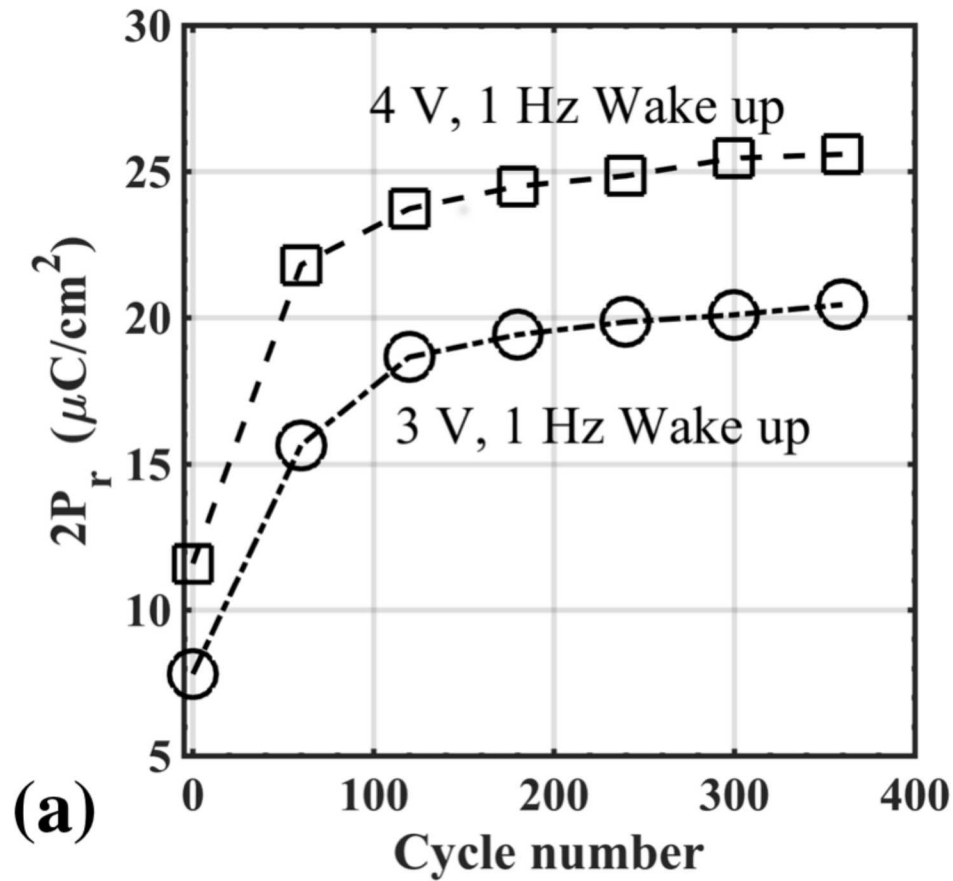


Variation of NbN/HZO/NbN Ferroelectric Response over Temperature



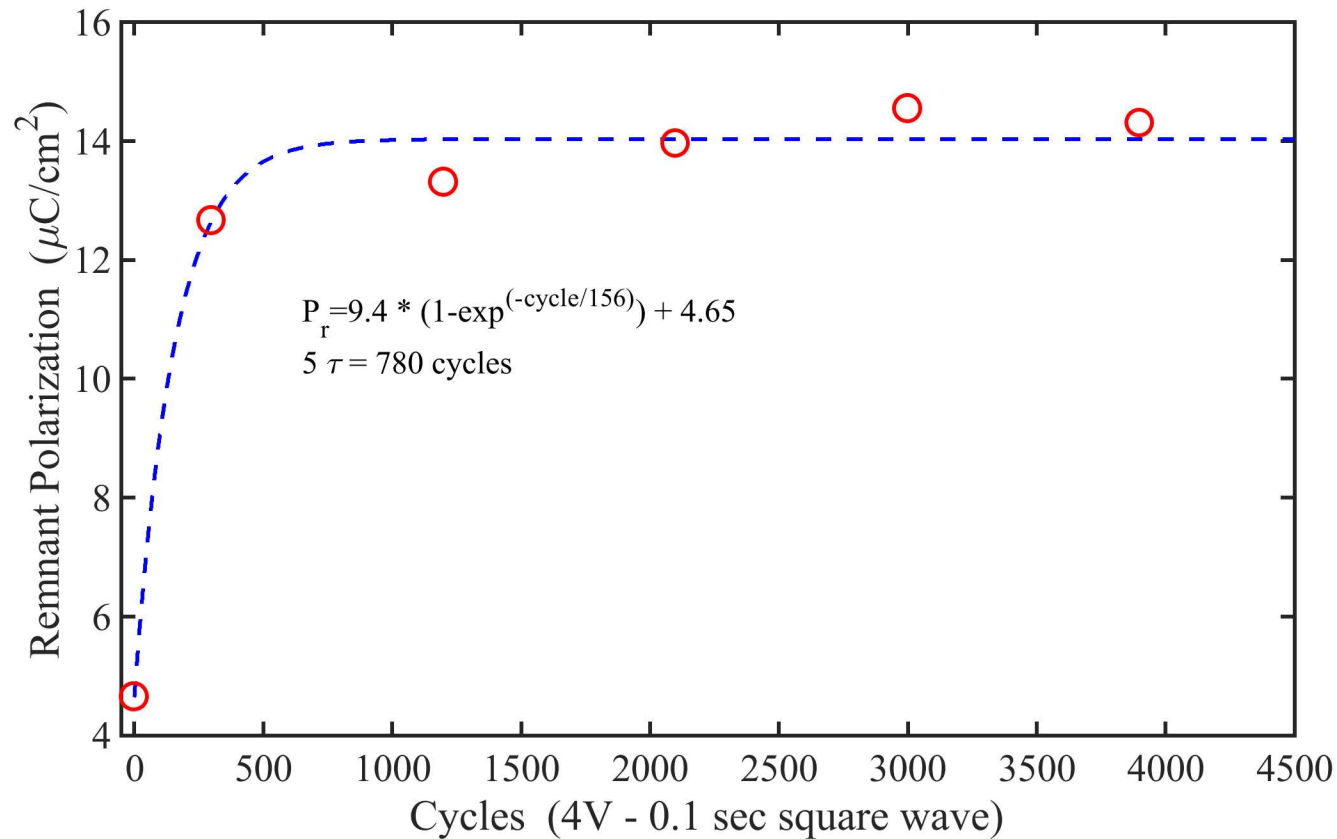
Extraction of remanent polarization separates the dielectric effect from the ferroelectric effect. When performed over temperature a slight decrease in polarization is observed. Approximately a $30 \mu\text{C}/\text{m}^2\text{K}$ decrease should occur and we measure about $100 \mu\text{C}/\text{m}^2\text{K}$; however this method does not isolate the pure pyroelectric phase.

9 Wake-up Effects of NbN/HZO/NbN at Room Temperature

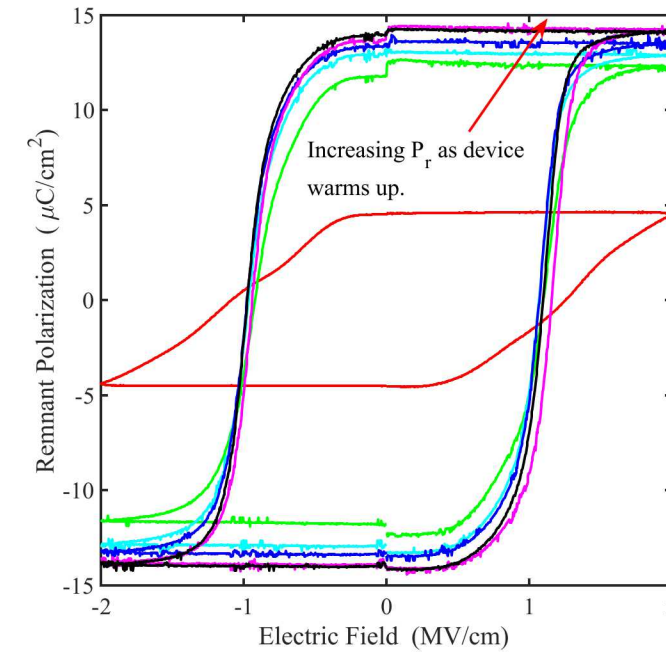


The wake-up effect is observed when the device is cycled from positive (3 or 4 V) to negative at relatively low frequencies. The regime is governed by a phase transformation from monoclinic to orthorhombic (Grimley et al-2016). A secondary effect is a reduction of a non-uniform defect rich tetragonal phase near the metal interface.

Wake-up Effects of NbN/HZO/NbN at Room Temperature



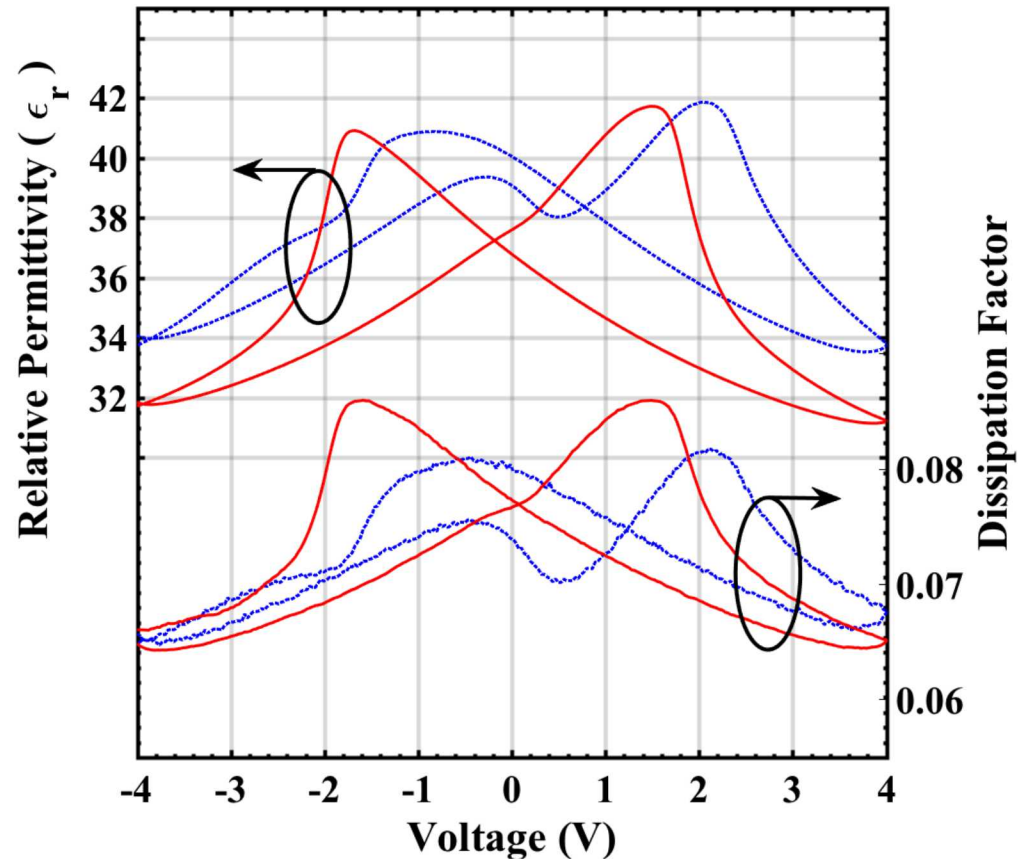
Wake up in a 77 μm radius NbN/HfZrO₂/NbN ferroelectric capacitor with a 20 nm film thickness using a 4 volt, 10 Hz cycle.



This wake-up is quickly observed by extracting the remanent polarization (at 0 volts) as polarization sweeps and square wave cycling of the film are intermixed.

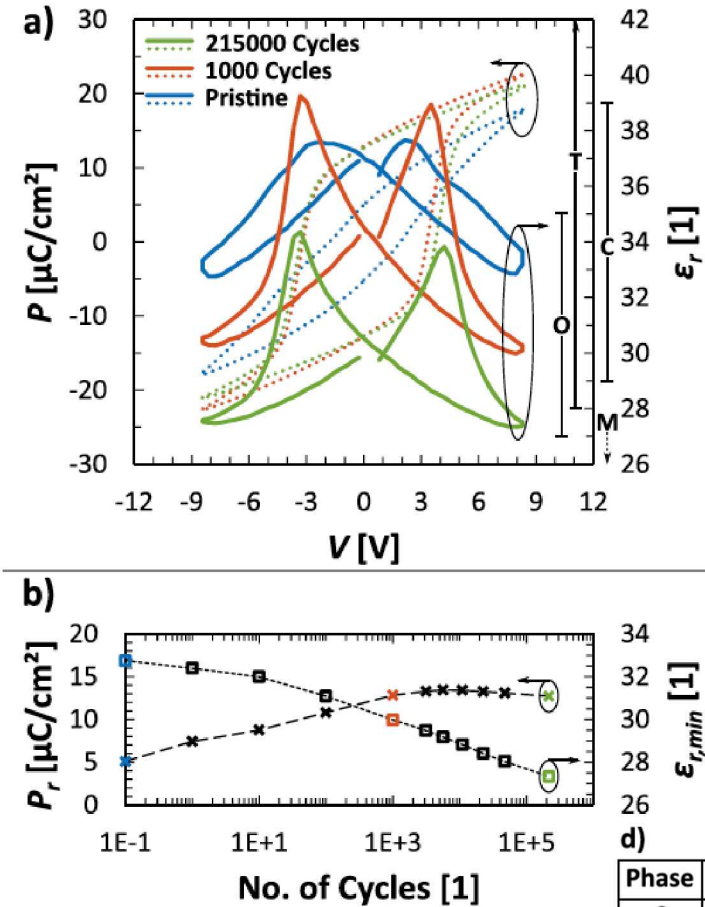
Wake-up Effects of NbN/HZO/NbN from Capacitance / Permittivity RT

NbN/Hf_{0.5}Zr_{0.5}O₂/NbN



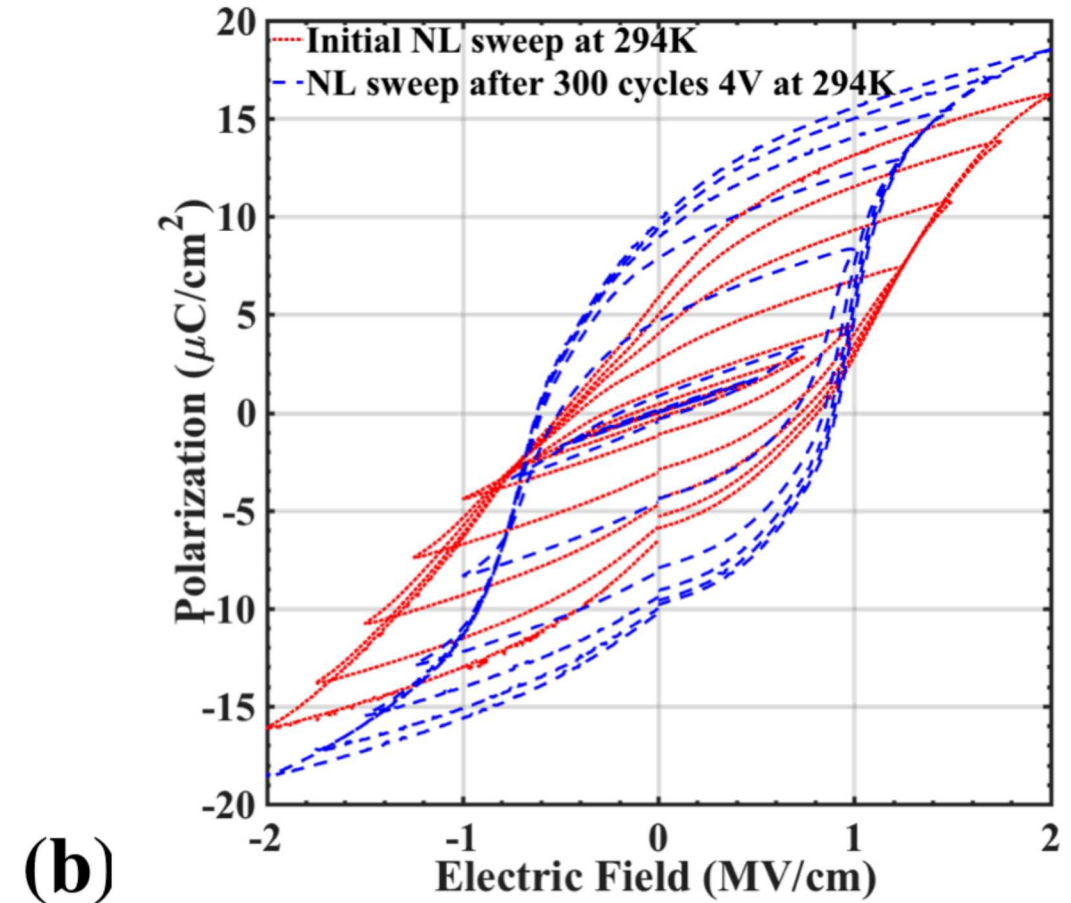
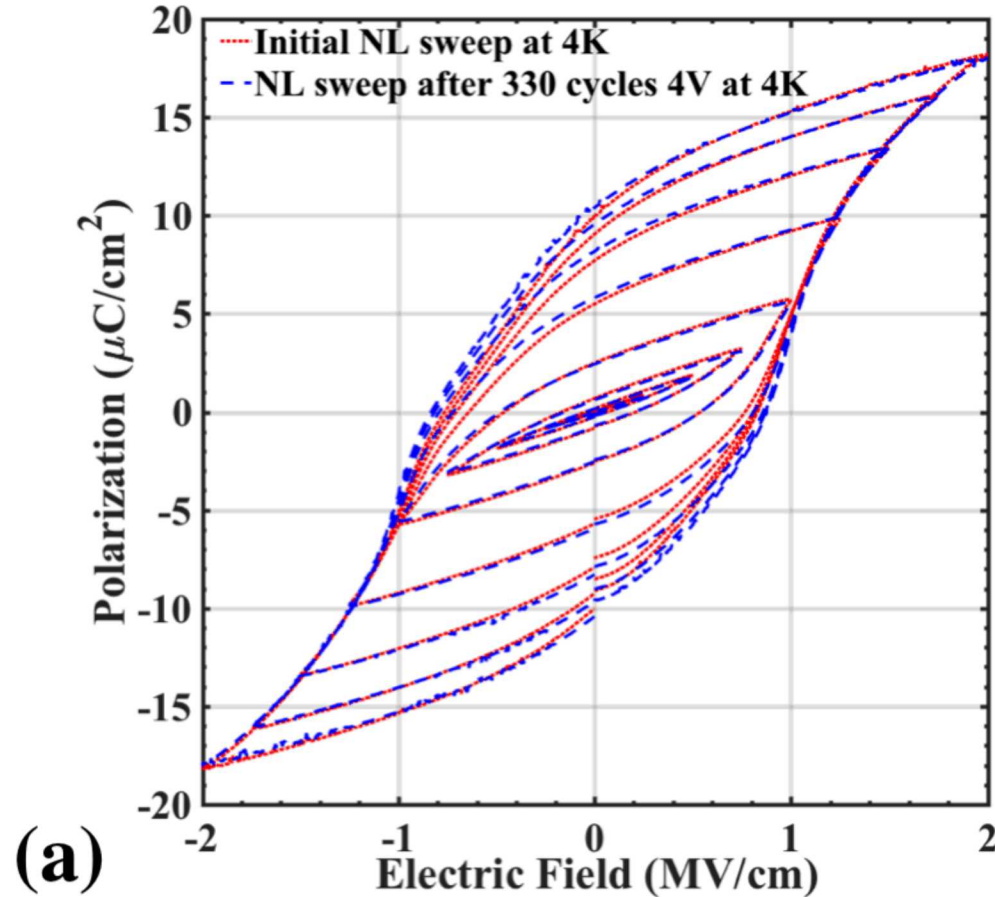
Relative permittivity and dissipation factor at 100 kHz as voltage is swept from -4 V to 4 V and then from 4 V to -4 V at room temperature before (blue dot) and after a 360 second, +/- 4 V and 1 Hz wakeup at room temperature (red line).

TiN/Gd:HfO₂/TiN



Phase	Space Group	ϵ_r [1]	References
C	$Fm3m$	$\epsilon_r = 29...39$	[2,48-51]
T	$P4_2/nmc$	$\epsilon_r = 28...70$	[2,49,51]
O (FE)	$Pca2_1$	$\epsilon_r = 27...35$	[2,48]
M	$P2_1/c$	$\epsilon_r = 16...20$	[2,48-51]

Wake-up Effects of NbN/HZO/NbN – Cryo WU vs RT WU

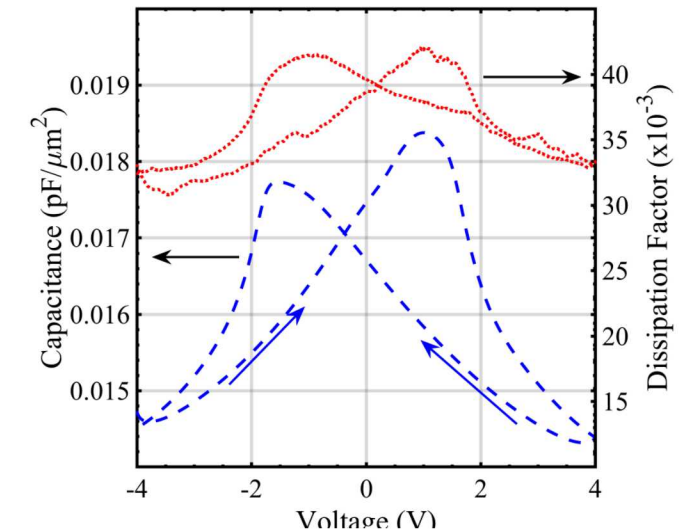
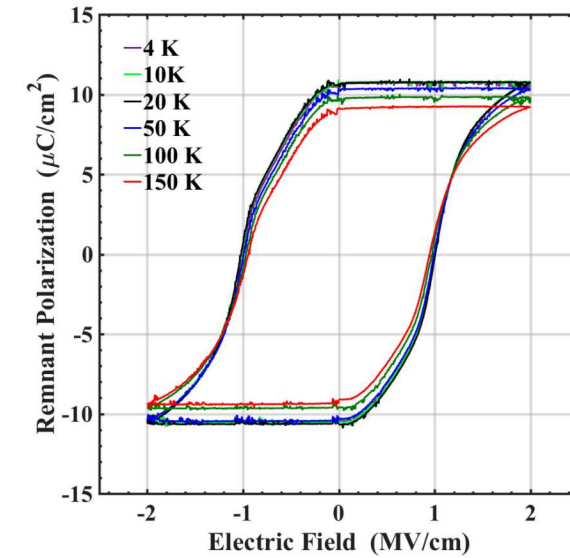


Oxygen vacancies at the top and bottom electrodes are speculated to be the source of the wake-up effect. At cryogenic temperatures, their mobility seems to freeze out at 4K.

This offers the intriguing potential for further studies of vacancy migration and possibilities for extending device life.

Conclusions

- This work has demonstrated ferroelectricity of HZO on superconducting NbN.
- Ferroelectricity of the films remain (no surprise) at 4 K however vacancy migration freezes out suppressing wake-up effects.
- Oxygen vacancy freeze out occurs suggesting a mechanism to study the wakeup effect.
- Potential applications in cryogenic or superconducting memory.



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